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DK 99
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REC'D 19 JUL 1999

WIPO PCT

Kongeriget Danmark

Patent application No.: PA 1998 00869
 Date of filing: 03 July 1998
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The attached photocopy is a true copy of the following document:

The specification, claims and drawings as filed with the application on the filing date indicated above.

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TAASTRUP 07 Jul 1999



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- 3 JULI 1998

FIELD OF THE INVENTION

The invention relates to securing of information utilizing imaging technologies and more specifically to phase and amplitude encryption and decryption of images.

5 BACKGROUND OF THE INVENTION

It is well known to form an image by phase contrast imaging methods in which phase modulation of light is converted into intensity modulation. As opposed to intensity modulation, phase modulation does not involve loss of energy.

- 10 In published patent application no. WO 96/34307 which is hereby incorporated by reference, a phase contrast imaging method is disclosed for calculating phasor values of a phase mask for synthesizing a desired intensity pattern.

- 15 In "Securing Information with Optical Technologies", Bahram Javidi, Physics Today Vol. 50, No. 3, March 1997, pp 27-32, a method and system for optically securing information is proposed. An image is encrypted in a 4f-lens optical configuration (i.e. comprising two Fourier transforming lenses) by Fourier transforming the image and an input phase
20 mask with a first lens of the 4f-lens system. A Fourier plane phase mask having phasor values $e^{ib(\alpha,\beta)}$ is positioned in the Fourier plane of the first lens and an encrypted image is formed with a second lens that Fourier transforms images in the Fourier plane of the first lens. The encrypted image is
25 decrypted in a similar 4f-lens configuration in which another Fourier plane phase mask (the key) having phasor values $e^{-ib(\alpha,\beta)}$ is positioned in the Fourier plane of the first lens.

- 30 It is a disadvantage of the known cryptographic method that encrypting an image both in the object plane and the Fourier plane leads to generation of speckle patterns in the

decrypted image thereby corrupting data having been encrypted.

It is another disadvantage of the known cryptographic method that extremely accurate three dimensional positioning of the
5 phase mask in the Fourier plane is required for successful encryption and decryption.

It is yet another disadvantage of the known cryptographic method that both amplitude and phase have to be recorded in the encrypted mask.

10 SUMMARY OF THE INVENTION

It is an object of the present invention to provide an apparatus of the above kind which apparatus is robust, compact, simple to design and relatively cheap to manufacture.

It is another object of the present invention to provide an
15 improved method and apparatus without the above-mentioned disadvantages.

It is still another object of the present invention to provide an improved method and apparatus for optically securing data utilizing phase contrast imaging.

20 According to the invention a method is provided of decryption of an encrypted image having a non-encrypted image intensity pattern $I(x', y')$.

The image is encrypted into a mask having a plurality of mask resolution elements (x_m, y_m) by encoding the image into the
25 mask with an encoded phase value $\phi(x_m, y_m)$ and an encoded amplitude value $a(x_m, y_m)$, and by encrypting the mask by addition of an encrypted phase value $\phi_c(x_m, y_m)$ to the encoded phase values $\phi(x_m, y_m)$ and by multiplication of an encrypted amplitude value $a_c(x_m, y_m)$ with the encoded amplitude value
30 $a(x_m, y_m)$. Thus, each mask resolution element (x_m, y_m)

modulates the phase and the amplitude of electromagnetic radiation incident upon it with the complex value $a(x_m, y_m) a_c(x_m, y_m) e^{i\phi(x_m, y_m) + i\phi_c(x_m, y_m)}$.

The method comprises the steps of radiating electromagnetic radiation towards the mask, and inserting into the path of the electromagnetic radiation a complex spatial electromagnetic radiation modulator comprising modulator resolution elements (x_d, y_d) , each modulator resolution element (x_d, y_d) modulating the phase and the amplitude of electromagnetic radiation incident upon it with a predetermined complex value $a_d(x_d, y_d) e^{i\phi_d(x_d, y_d)}$, the decrypting phase value $\phi_d(x_d, y_d)$ and the decrypting amplitude value $a_d(x_d, y_d)$, respectively, of a modulator resolution element (x_d, y_d) being substantially equal to $-\phi_c(x_m, y_m)$ and $a_c^{-1}(x_m, y_m)$, respectively, of a corresponding mask resolution element (x_m, y_m) , and imaging the mask and the electromagnetic radiation modulator onto the image having the image intensity pattern $I(x', y')$.

The complex spatial electromagnetic radiation modulator may be positioned anywhere in the path of the electromagnetic radiation. When the complex modulator is positioned adjacent to the mask, the encrypted mask is decrypted when the decrypting phase value $\phi_d(x_d, y_d)$ and the decrypting amplitude value $a_d(x_d, y_d)$, respectively, of a modulator resolution element (x_d, y_d) being substantially equal to $-\phi_c(x_m, y_m)$ and $a_c^{-1}(x_m, y_m)$, respectively, of a corresponding adjacent and aligned mask resolution element (x_m, y_m) . The complex modulator may be physically positioned remotely from the mask and imaged onto the position of the mask whereby the complex modulator is virtually positioned adjacent to the mask. The complex modulator may be positioned virtually or physically in another position than adjacent to the mask still performing the decrypting function when the amplitude and phase values of the complex modulator are transformed accordingly, e.g. by a Fresnel propagator.

It is an important advantage of the present invention that the encrypted image may selectively require recording of phase values or amplitude values or a combination thereof.

It is another advantage of the present invention that
5 decryption is performed in a plane adjacent to the mask or an equivalent plane whereby generation of speckles in the decrypted image is suppressed.

It is yet another advantage of the present invention that there is no requirement of positioning a radiation modulator
10 in the Fourier plane whereby an accurate three dimensional positioning requirement is avoided.

It is still another advantage of the present invention that only a single key for encryption is required.

It is preferred to encode the non-encrypted image into a
15 phase mask and encrypt the phase mask by adding encrypting phase values to the encoded phase values. An encrypted phase mask is extremely difficult - if not impossible - to replicate by counterfeiters. Further, phase masks may be readily produced while masks requiring recording of both
20 amplitude and phase are extremely complicated to produce, typically requiring production of two masks to be accurately superpositioned. The same applies to the decrypting complex modulator.

The imaging may be performed with a common path
25 interferometer, such as a phase contrast imaging system, a dark field imaging system, a field absorption imaging system, a point diffraction imaging system, a Smartt interferometer, a Schlieren interferometer, etc, and any combination hereof.

According to a preferred embodiment of the invention a method
30 is provided for synthesizing an intensity pattern with low loss of electromagnetic energy, comprising spatial modulation of electromagnetic radiation with a spatial phase mask for

modulation of the phase of the incident electromagnetic radiation by phasor values of individual resolution elements of the spatial phase mask, each phasor value being determined in such a way that

- 5 1) the values of the Fourier transformed phasors attains predetermined values for predetermined spatial frequencies, and
- 2) the phasor value of a specific resolution element of the spatial phase mask corresponds to a distinct
10 intensity level of the image of the resolution element in the intensity pattern,

and a spatial phase filter for phase shifting of a part of the electromagnetic radiation, in combination with an imaging system for generation of the intensity pattern by interference in the image plane of the imaging system between the
15 part of the electromagnetic radiation that has been phase shifted by the phase filter and the remaining part of the electromagnetic radiation.

Although, the present method is related to encoding of spatial phase masks in two spatial dimensions (planar encoding),
20 the principles of the method may be utilized for phase encoding in one to three spatial dimensions and/or in the temporal dimension.

The electromagnetic radiation may be of any frequency range
25 of the electromagnetic spectrum, i.e. the gamma frequency range, the ultraviolet range, the visible range, the infrared range, the far infrared range, the X-ray range, the microwave range, the HF (high frequency) range, etc. The present method is also applicable to particle radiation, such as electron
30 radiation, neutron radiation, etc.

Preferably, the electromagnetic radiation is monochromatic or quasi-monochromatic so that the energy of the electromagnetic

radiation is concentrated in a narrow frequency bandwidth. As the intensity pattern is synthesized by interference of two electromagnetic waves emitted from a common source of electromagnetic radiation but the phases of which have been

5 changed differently, it is required that the frequency range of the emitted electromagnetic radiation is sufficiently narrow to ensure that the two waves of electromagnetic radiation are coherent so that their superposition generates the desired intensity pattern. If the frequency range is too

10 broad, the two waves will be incoherent and the phase information will be lost as superposition of non-coherent waves results in a summation of the intensities of the two waves. It is required that the difference between individual delays of electromagnetic radiation to be superpositioned is less

15 than the wavelength of the radiation. This is a relaxed requirement that allows the electromagnetic radiation to be relatively broad-banded. For example in the visible range a Xe-lamp or a Hg-lamp can be used as a light source in a system according to the present invention with the advantage

20 compared to a laser light source that the speckle noise is reduced. The requirements of the spatial coherence of the electromagnetic radiation depend upon the space bandwidth product of the corresponding system and how close the required system performance is to the theoretically obtain-

25 able performance of the system.

Preferably, the electromagnetic radiation is generated by a coherent source of electromagnetic radiation, such as a laser, a maser, a phase-locked laser diode array, etc. However a high pressure arc lamp, such as a Hg lamp, a Xe lamp,

30 etc, may also be used and even an incandescent lamp may be used as a source of electromagnetic radiation in a low performance system.

A spatial phase mask is a component that changes the phase of an electromagnetic wave incident upon it. The spatial phase

35 mask may transmit or reflect the incident electromagnetic wave. Typically, the spatial phase mask is divided into a

number of resolution elements each of which modulates the incident electromagnetic wave by changing its phase by a specific predetermined value. The predetermined values are assigned to each resolution element in different ways depending upon the technology applied in the component. For example in spatial light modulators, each resolution element may be addressed either optically or electrically. The electrical addressing technique resembles the addressing technique of solid-state memories in that each resolution element can be addressed through electronic circuitry to receive a control signal corresponding to the phase change to be generated by the addressed resolution element. The optical addressing technique addresses each resolution element by pointing a light beam on it, the intensity of the light beam corresponding to the phase change to be generated by the resolution element illuminated by the light beam.

Spatial phase masks may be realized utilizing fixed phase masks, devices comprising liquid crystals and being based on liquid crystal display technology, dynamic mirror devices, digital micromirror arrays, deformable mirror devices, membrane spatial light modulators, laser diode arrays (integrated light source and phase modulator), smart pixel arrays, etc.

A spatial phase filter is typically a fixed phase mask, such as an optically flat glass plate coated with a dielectric layer at specific positions of the glass plate. However, the spatial phase masks mentioned in the previous section may also be used for spatial phase filters.

The imaging system maps the phase modulating resolution elements of the spatial phase mask on the target surface of the synthesized intensity pattern. It may comprise a 4f-lens configuration (two Fourier transforming lenses utilizing transmission of light or one Fourier transforming lens utilizing reflection of light) or a single imaging lens. However, any optical imaging system providing a filtering plane for

the spatial phase filter may be applied in a phase contrast imaging system.

In the method according to the present invention, the synthesized intensity pattern is generated by superposition of two electromagnetic waves in the image plane of the imaging system. The spatial phase mask changes the phase values of an electromagnetic wave incident upon it and the imaging system directs the electromagnetic wave with changed phases reflected from or transmitted through the spatial phase mask towards the spatial phase filter. The phase filter phase shifts a part of the electromagnetic radiation and the imaging system is adapted to superimpose in the image plane the phase shifted part of the electromagnetic radiation with the part of the electromagnetic radiation that is not phase shifted by the spatial phase filter.

According to a preferred embodiment of the invention, the spatial phase mask is positioned at the front focal plane of a lens while the spatial phase filter is positioned in the back focal plane of the lens, whereby a first electromagnetic field at the phase mask is Fourier transformed by the lens into a second electromagnetic field at the phase filter. Thus, specific spatial frequencies of the first electromagnetic field will be transmitted through the spatial phase filter at specific positions of the phase filter. For instance, the energy of the electromagnetic radiation at zero frequency (DC) is transmitted through the phase filter at the intersecting point of the Fourier plane and the optical axis of the lens also denoted the zero-order diffraction region.

It is presently preferred that the spatial phase filter is adapted to phase shift the DC-part of the electromagnetic radiation and to leave the remaining part of the electromagnetic radiation unchanged or, alternatively, to leave the DC-part of the electromagnetic radiation unchanged and to phase shift the remaining part of the electromagnetic radiation. The last alternative is preferred when the energy level of

the DC-part of the electromagnetic radiation is so high that the phase shifting part of the phase filter will be destroyed by it. For example in laser cutting, the DC level of the laser beam can be so high that a phase shifting dot positioned at the intersecting point of the DC part of the laser beam at the phase filter would evaporate. It is also possible to block the electromagnetic radiation (no transmittance) in the zero-order diffraction region, however, the DC energy of the radiation is then lost.

- 10 Below, an expression of the intensity of the synthesized intensity pattern as a function of the phasor values $\phi(x,y)$ of the phase mask, when the DC-part of the electromagnetic radiation is phase shifted, is deduced.

Electromagnetic radiation incident on the spatial phase mask can be described by a function $A(x,y)$, where $A(x,y)$ is a complex number (amplitude and phase) of the incident field on the point (x,y) of the spatial phase mask. At the point (x,y) , the spatial phase mask modulates the phase of the incident radiation with a value $\phi(x,y)$ so that the field after reflection by or transmission through the spatial phase mask may be described by the function $A(x,y) * e^{i\phi(x,y)}$, $e^{i\phi(x,y)}$ being the phasor value of the point (x,y) of the spatial phase mask. As $A(x,y)$ preferably is a constant value over the entire surface of the spatial phase mask, the term is left out of the following equations for simplicity.

The expression of the electromagnetic radiation incident on the spatial phase filter may now be separated into an AC-term and a DC-term. If the DC-term of the field is denoted $\bar{\alpha}$, the AC-term of the field is given by the term $e^{i\bar{\alpha}(x,y)} - \bar{\alpha}$. As the spatial phase filter changes the phase of the DC-part of the electromagnetic radiation by θ , the intensity of the synthesized intensity pattern at the image plane of the imaging system is given by:

$$I(x',y') = |e^{i\phi(x',y')} + \bar{\alpha}(e^{i\theta} - 1)|^2$$

wherein (x', y') is the coordinates of the image of the point (x, y) of the spatial phase mask formed by the imaging system in the image plane.

It should be noted that the second term of the equation is a
5 complex number that adds to the phasors $e^{i\phi(x,y)}$ of the spatial phase mask and may be interpreted as a contrast control parameter for the synthesized intensity pattern $I(x', y')$.

According to a preferred embodiment of the invention, the
10 average value of the phasors is adjusted in order to control the range of intensity levels.

Instead of phase shifting the DC-part of the electromagnetic radiation, it is also possible to synthesize a prescribed intensity pattern by phase shifting other parts of the electromagnetic radiation by adapting the spatial phase filter to
15 phase shift electromagnetic radiation incident upon one or more arbitrary regions of the phase filter and leaving the phase of the remaining part of the electromagnetic radiation unchanged and then superimposing the two parts of the electromagnetic radiation. The corresponding mathematics and the
20 corresponding design procedures for the spatial phase mask and spatial phase filter will of course be more complicated than for the method described in the previous section.

A simple example of phase shifting a part of the electromagnetic radiation of a spatial frequency different from the
25 zero frequency is provided by moving the DC-part of the electromagnetic radiation to another spatial frequency in the Fourier plane (identical to the plane of the spatial phase filter) utilizing an optical component with an appropriate carrier frequency (i.e. a grating or a prism) or, preferably,
30 encoding the function of a grating or a prism into the spatial phase mask, and adapting the spatial phase filter to change the phase of the electromagnetic radiation at this spatial frequency and to leave the phase of the remaining part of the electromagnetic radiation unchanged.

According to another preferred embodiment of the invention, the phase mask is not positioned in the back focal plane of the lens but in the Fresnel region of the lens instead. In this case, the electromagnetic field at the phase filter will
 5 be given by a Fresnel transformation of the electromagnetic field at the spatial phase mask. This further complicates the mathematics and the design procedures, for example the term $\bar{\alpha}$ in equation (7) has to be substituted by the value of the Fresnel transformation at the point(s) of phase changes of
 10 the phase filter. However, the Fresnel transformation may be calculated from a Fourier transformation by multiplication of the phasor values of the spatial phase mask by a quadratic phase factor followed by a Fourier transformation.

It is an important aspect of the present invention that each
 15 intensity level of the synthesized intensity pattern for each resolution element may be generated by at least two different phasor values of a resolution element of the spatial phase mask.

For example, when the spatial phase filter phase shifts the
 20 DC-part of the electromagnetic radiation, it will be shown later that, advantageously, the average $\bar{\alpha}$ of the phasors of the resolution elements of the phase mask should be equal to $\frac{1}{2}$ and the value of the phase shift θ should be equal to π . In this case, the intensity of the synthesized image pattern at
 25 the image (x', y') of the resolution element (x, y) will be given by:

$$I(x', y') = 2(1 - \cos\phi(x', y'))$$

It is seen that complex conjugate phasors (values of ϕ of opposite sign) result in identical intensity levels $I(x', y')$.
 30 It can be shown that for any value of the modulus of the average of the phasors $|\bar{\alpha}|$, two phasors exist that will generate identical intensity levels of the synthesized intensity pattern.

Further, if the spatial phase filter phase shifts parts of the electromagnetic radiation different from the DC-part, the phasor value that generates a specific intensity level will depend on the position of the resolution element in question, 5 i.e. the phasor value and the position of the resolution element with that phasor value together define the intensity level at the image of the resolution element in the synthesized intensity pattern. Still, it is true that for each resolution element of the spatial phase mask, each intensity 10 level of the synthesized intensity pattern may be represented by one of two different phasors of complementary phase values.

This freedom of being able to select, for each intensity level to be generated and for each resolution element of the 15 spatial phase mask, one of two phasors is used to control the phase of the Fourier transform of the phasors at specific spatial frequencies by selection of phasors with appropriate phase values to ensure two intervals of biunique functional dependence between phasor values and corresponding intensity 20 values.

This freedom of choice of phasors may be utilized to select phasors of neighbouring resolution elements of the spatial phase mask with a maximum difference between them, thereby generating an electromagnetic radiation emitted from the 25 phase mask with a maximum content of high spatial frequencies which will generate a good separation of the DC part of the electromagnetic radiation from its AC part. However, any other strategy of selecting between two possible phasor values of each resolution element may be chosen to generate a 30 desired spatial frequency content of the electromagnetic radiation.

Preferably, the phase of the Fourier transform of the phasors at specific spatial frequencies is adjusted in order to control whether the relation between each phasor and the

corresponding intensity level is a monotonic increasing or a monotonic decreasing function.

Below, a set of different methods are described that are provided according to the present invention for adjustment of
5 the modulus of the Fourier transform of the phasors at specific spatial frequencies to attain a prescribed value. If convenient, the methods may be combined.

According to one of the methods, the individual phasors of the resolution elements of the phase mask are adjusted by a
10 constant value until the desired value of the modulus of the Fourier transform of the phasors at specific spatial frequencies is attained while maintaining prescribed relative intensity levels between intensities of resolution elements of the intensity pattern, i.e. iteratively.

15 According to another method, the individual phasors of the resolution elements of the phase mask are adjusted utilizing histogram techniques known from image processing. A histogram is a bar chart showing the number of resolution elements of the synthesized intensity pattern with a specific intensity
20 value as a function of the intensity value. Any histogram technique, such as histogram equalization, adapting the histogram to a predetermined distribution, etc., may be used iteratively until the modulus of the Fourier transform of the phasors at specific spatial frequencies attain the prescribed
25 value.

According to yet another method, the phasor pattern of the phase mask is spatially scaled in order to adjust the modulus of the Fourier transform of the phasors at specific spatial frequencies.

30 According to still another method, the modulus of the Fourier transform of the phasors at specific spatial frequencies is adjusted utilizing half tone coding techniques, such as

raster techniques, area ratio modulation, spot diameter modulation, etc.

It is seen from the description above that the intensity levels may differ from one synthesized intensity pattern to the next as a consequence of the adjustments of the modulus of the Fourier transform of the phasors at specific spatial frequencies. Thus, it is preferred to control the power of the radiation source in dependence of the intensity range of the intensity pattern so that a sequence of different intensity patterns show uniform intensity levels.

According to a preferred embodiment of the invention, the shape of the phase filter is adapted to match the spatial frequency content of the phasors of the spatial phase mask, e.g. to optimize the desired separation of the part of the electromagnetic radiation to be phase filtered from the remaining part of the electromagnetic radiation.

It is within the scope of the present invention that the imaging system further comprises zooming means for variable scaling of the synthesized intensity pattern. The zooming of the imaging system may be dynamically controllable, e.g. in response to the scaling of the pattern of phasor values of the phase mask.

According to the present invention, the power of the radiation source may be controllable in response to the spatial scaling of the pattern in the phase mask and/or the zooming of the focusing system.

In order to provide a compact and integrated system according to the present invention, the optical function of a Fourier-transforming lens is encoded into the phasors of the spatial phase mask. The Fourier transforming lens may be refractively or diffractively encoded into the phase mask.

Similarly, the optical function of an output lens may be encoded into the phase filter either refractively or diffractively.

Further, a compensation may be encoded into the phasor values of the spatial phase mask so that part of the electromagnetic radiation modulated by the phase mask has a substantially flat intensity profile in the image plane. Without this compensation, part of the electromagnetic radiation modulated by the phase mask will have a flat profile with perturbations resulting from the phase filtering superpositioned upon it. This may cause "ringings" (oscillations) at the edges of the synthesized intensity pattern.

According to another preferred embodiment of the invention, the source of electromagnetic radiation comprises one or more light sources of different wavelengths corresponding to three different colours, such as red, green and blue, for generation of intensity patterns of arbitrary colours. Further, several independent systems each one illuminated by its own wavelength can be combined into a single multi-wavelength system.

BRIEF DESCRIPTION OF THE DRAWINGS

Fig. 1 shows a 4f common path interferometer,

Fig. 2 shows a 2f common path interferometer,

Fig. 3 shows a 1f common path interferometer,

Fig. 4 shows (A) off-axis read-out of reflective SLM and (B) on-axis read-out of reflective SLM.

Fig. 5 shows schematically an example of a prescribed intensity pattern in 1D.

Fig. 6 shows schematically the resulting phase encoding corresponding to Fig. 5.

DETAILED DESCRIPTION OF PREFERRED EMBODIMENTS

- Fig. 1 shows a 4f common path interferometer (1). A laser (2) emits a light beam which is expanded by a beam expander (3) into a plane light wave of uniform intensity and directs it towards a combination of an encrypted mask and a complex spatial electromagnetic radiation modulator (4). The light beam is transmitted through the combination (4) and a Fourier transforming lens (5). The combination (4) is positioned in the front focal plane of the lens (5) and a spatial filter (6) is positioned in the back focal plane of the lens (5) that is also the front focal plane of a lens (7). The Fourier transforming lenses (5, 7) need not have identical focal lengths. Different focal lengths lead to a magnification ratio different from one. The filter (6) phase shifts by θ and optionally attenuates (by a factor B) the zero order diffraction part (8) of the light modulated by the combination (4). Optionally, the remaining diffraction part of the light modulated by the combination (4) may be attenuated by a factor A. The synthesized intensity pattern is generated in the back focal plane (9) of the lens (7) and a dynamic focusing system (10) images the synthesized intensity pattern onto a focusing plane (11).
- The optical system is controlled by a computer (12). The computer (12) comprises interface means for addressing each of the resolution elements of the complex spatial electromagnetic radiation modulator (4) and transmitting a decrypting value to the addressed resolution element.
- Optionally, the phase shift θ and attenuation factors (A, B) of the filter (6) is adjustable and controllable by optional phase control means of the computer (12) which may be further adapted to adjust the phase shift, e.g. utilizing equation (18).

Fig. 2 shows a $2f$ common path interferometer (20). A laser (21) emits a light beam which is expanded by a beam expander (22) into a plane light wave of uniform intensity and directs it towards a combination of an encrypted mask and a complex spatial electromagnetic radiation modulator (23) and a polarization beam splitter (24) and a quarter-wave plate (25). The polarization beam splitter (24) and the quarter-wave plate (25) allows beam-splitting of light of a specific linear polarization without the power loss associated with conventional beam-splitters due to splitting of the beam in both directions of transmission through the beam-splitter. After transmission through the polarization beam splitter (24) and the quarter-wave plate (25), the light beam is transmitted through a Fourier transforming lens (26) and is reflected from a spatial filter (27). The combination (23) is positioned in the front focal plane of the lens (26) and the spatial filter (27) is positioned in the back focal plane of the lens (26). The filter (27) phase shifts by θ and optionally attenuates (by a factor B) the zero order diffraction part (28) of the light modulated by the combination (23). Optionally, the remaining diffraction part of the light modulated by the combination (23) may be attenuated by a factor A. The synthesized intensity pattern is generated in the back focal plane (29) of the lens (26) and a dynamic focusing system (30) images the synthesized intensity pattern onto a focusing plane (31). As described for the system shown in Fig. 1, the system (20) is controlled by a computer (32).

Fig. 3 shows a $1f$ common path interferometer (40). A laser (41) emits a light beam which is expanded by a beam expander (42) into a plane light wave of uniform intensity and directs it towards a combination of an encrypted mask and a complex spatial electromagnetic radiation modulator (43). The light beam is transmitted through the combination (43) and an image forming lens (44). The filter (45) phase shifts by θ and optionally attenuates (by a factor B) the zero order diffraction part of the light modulated by the combination

(43). Optionally, the remaining diffraction part of the light modulated by the combination (43) may be attenuated by a factor A. The synthesized intensity pattern is generated in the image plane (46) of the lens (44) and a dynamic focusing system (47) images the synthesized intensity pattern onto a focusing plane (48). As described for the system shown in Fig. 1, the system (40) is controlled by a computer (49).

Fig. 4 shows details of (Fig. 4A) an off-axis read-out of a combination of a reflective mask and a complex spatial electromagnetic radiation modulator (50) and of (Fig. 4B) an on-axis read-out of combination of a reflective mask and a complex spatial electromagnetic radiation modulator (51) with a beam splitter (52). Both configurations (Fig. 4A, Fig. 4B) may be utilized in the systems shown in Figs. 1-3.

PHASE ENCODING FOR DC PHASE FILTERING

In the following an example of encoding a spatial phase mask and a spatial phase filter will be given based on a system filtering in the DC-frequency range. The system chosen in this example is based on a 4-f lens configuration as shown in Fig. 1 and illuminated by electromagnetic radiation in the visible frequency domain, hereafter simply denoted as *light* radiation.

10

Assuming that the illuminating light is monochromatic and has a substantially flat amplitude profile we obtain the following spatial amplitude distribution emitted from the spatial phase mask:

15

$$a(x, y) = \text{rect}\left(\frac{x}{\Delta x}, \frac{y}{\Delta y}\right) \exp(i\phi(x, y)) \quad (1)$$

where $a(x, y) = \exp(i\phi(x, y))$ represent the spatially encoded phasor values and $\Delta x \Delta y$ is the area of the input phase modulating spatial light modulator.

20

It turns out to be convenient to separate $a(x, y)$ into two terms describing a spatially invariant DC-value, \bar{a} , and a spatially varying AC-contribution $\Delta a(x, y)$. The DC-value can be found as:

25

$$\bar{a} = \frac{1}{\Delta x \Delta y} \iint_{\Delta x \Delta y} \exp(i\phi(x, y)) dx dy \quad (2)$$

Subsequently the AC-term is expressed by:

30

$$\Delta a(x, y) = \exp(i\phi(x, y)) - \frac{1}{\Delta x \Delta y} \iint_{\Delta x \Delta y} \exp(i\phi(x, y)) dx dy \quad (3)$$

The separation of $\alpha(x, y)$ into a spatially invariant DC-term and a spatially varying AC-term is an important point and will be used throughout the remaining part of this example, especially in the description of the spatial filtering procedure.

The spatial filter utilized in this example is chosen as a circular phase contrast filter (different transverse shapes can also be used) centered around origo in the the spatial frequency domain, denoted by coordinates (f_x, f_y) :

$$T(f_r) = 1 + (\exp(i\theta) - 1)\text{circ}\left(\frac{f_r}{\Delta f_r}\right) \quad (4)$$

where $f_r = \sqrt{f_x^2 + f_y^2}$ denotes radial spatial frequency and Δf_r describes the size of the circular (circ) phase filter.

In the spatial frequency domain (the filtering plane) the Fourier transformation (\mathfrak{F}) of the spatially modulated light radiation from the spatial phase mask is present. The filtering operation on the Fourier transformed light radiation performed by the spatial phase contrast filter can be expressed as a simple point-by-point multiplication procedure. Subsequently the spatially filtered light is inverse Fourier transformed (\mathfrak{F}^{-1}) by the second Fourier lens (Fourier transformation and reflected output coordinates) and the resulting spatial amplitude distribution in the image plane (with coordinates (x', y')) can accordingly be written as:

$$\begin{aligned}
\alpha(x', y') &= a(x', y') + (\exp(i\theta) - 1) \mathfrak{I}^1 \left(\mathfrak{I}(a(x, y)) \text{circ} \left(\frac{f_r}{\Delta f_r} \right) \right) \\
&\equiv a(x', y') + \bar{a}(\exp(i\theta) - 1) \text{rect} \left(\frac{x'}{\Delta x}, \frac{y'}{\Delta y} \right) \\
&= [\exp(i\phi(x', y')) + \bar{a}(\exp(i\theta) - 1)] \text{rect} \left(\frac{x'}{\Delta x}, \frac{y'}{\Delta y} \right)
\end{aligned} \tag{5}$$

Within the illumination-region, $(x', y') \in \mathfrak{R}'$, outlined by $\text{rect} \left(\frac{x'}{\Delta x}, \frac{y'}{\Delta y} \right)$, one obtains:

5

$$|\alpha(x', y')|^2 \equiv 1 + 4|\bar{a}| \sin\left(\frac{\theta}{2}\right) \left[|\bar{a}| \sin\left(\frac{\theta}{2}\right) - \sin\left(\phi_a - \phi(x', y') + \frac{\theta}{2}\right) \right] \tag{6}$$

Requiring that $|\alpha(x'_0, y'_0)|^2 \equiv 0$ corresponding to complete darkness as the lowest intensity level in
10 regions $(x'_0, y'_0) \in \mathfrak{R}'_0$ implies:

$$1 + 4|\bar{a}| \sin\left(\frac{\theta}{2}\right) \left[|\bar{a}| \sin\left(\frac{\theta}{2}\right) - \sin\left(\phi_a - \phi_0 + \frac{\theta}{2}\right) \right] = 0 \tag{7}$$

where the abbreviation $\phi_0 = \phi(x'_0, y'_0)$ has been used.

15

The solutions to Eq. (7) are given by:

$$|\bar{a}| = \frac{\sin\left(\phi_a - \phi_0 + \frac{\theta}{2}\right) \pm \sqrt{\sin^2\left(\phi_a - \phi_0 + \frac{\theta}{2}\right) - 1}}{2 \sin\left(\frac{\theta}{2}\right)} \tag{8}$$

20 The requirement $0 < |\bar{a}| < 1$ implies that:

$$\begin{aligned}\sin^2\left(\phi_a - \phi_o + \frac{\theta}{2}\right) &= 1 \Rightarrow \\ \theta &= \pi - 2(\phi_a - \phi_o) + p2\pi, \quad p = 0, \pm 1, \pm 2, \dots\end{aligned}\quad (9)$$

leading to

$$|\alpha| = \frac{\pm 1}{2 \sin\left(\frac{\theta}{2}\right)} \Rightarrow \frac{1}{2} \leq |\alpha| < 1 \quad (10)$$

5

where the +sign is for θ -values in the interval:

$$\theta \in \left] \frac{\pi}{3}; \frac{5\pi}{3} \right[+ p_{\text{even}} 2\pi \quad (11)$$

10 and the -sign is for θ -values:

$$\theta \in \left] \frac{\pi}{3}; \frac{5\pi}{3} \right[+ p_{\text{odd}} 2\pi \quad (12)$$

The corresponding interval for $(\phi_a - \phi_o)$ is:

15

$$(\phi_a - \phi_o) \in \left] \frac{\pi}{3}; -\frac{\pi}{3} \right[\quad (13)$$

Inserting the expression for $|\alpha|$, one obtains the simple intensity expression:

20

$$|\alpha(x', y')|^2 = 2 \left[1 \mp \sin\left(\phi_a - \phi(x', y') + \frac{\theta}{2}\right) \right] \quad (14)$$

where

$$\iint_{\Delta x \Delta y} \exp(i\phi(x, y)) dx dy = \Delta x \Delta y |\alpha| \exp(i\phi_a) \quad (15)$$

25 The phase-only transformations imply that energy is conserved:

$$\iint_{\Delta x \Delta y} |\alpha(x', y')|^2 dx' dy' = \iint_{\Delta x \Delta y} |a(x, y)|^2 dx dy = \Delta x \Delta y \quad (16)$$

5 A special case:

The most convenient choice for $\bar{\alpha}$ is: $\bar{\alpha} = \frac{1}{2}$ (implying that $\theta = \pi + p_{\text{even}} 2\pi$), so that the output intensity can be described as:

$$10 \quad |\alpha(x', y')|^2 = 2[1 - \cos(\phi(x', y'))] \quad (17)$$

In this case the phase \rightarrow intensity mapping is described by the intervals $[0; \pi] \rightarrow [0; 4]$.

By setting $\bar{\alpha} = \frac{1}{2}$ one obtains the following requirement to
15 the phase function $\phi(x, y)$:

$$\begin{cases} \iint_{\Delta x \Delta y} \cos(\phi(x, y)) dx dy = \frac{\Delta x \Delta y}{2} \\ \iint_{\Delta x \Delta y} \sin(\phi(x, y)) dx dy = 0 \end{cases} \quad (18)$$

Inserting the expression for $|\alpha(x', y')|^2$ in Eq. (16) yields:
20

$$2 \iint_{\Delta x \Delta y} [1 - \cos(\phi(x', y'))] dx' dy' = \Delta x \Delta y \quad (19)$$

in accordance with the first of the integral expressions in Eq. (18).

Encoding procedure:

- A given intensity distribution (image) $|\alpha(x', y')|^2$ is desired at the output side of the optical setup.

5

- Pixellation of the image, that is generally represented in the greyscale range: $[0; gmax]$, provides the relation:

$$\iint |\alpha(x', y')|^2 dx' dy' = \Delta x \Delta y \Rightarrow \sum_{ij} |\alpha(i, j)|^2 = \frac{gmax}{4} \# \text{pix}_{(\Delta x \Delta y)}.$$

10

- The histogram for the desired image $|\alpha(i, j)|^2$ is adjusted (adj) within the greyscale range $[0; gmax]$, so that the previous point is fulfilled:

$$|\alpha(i, j)|^2 \rightarrow |\alpha(i, j)|_{adj}^2.$$

15

- The phase values can now be calculated as:

$$\phi(i, j) = \arccos \left(1 - \frac{2|\alpha(i, j)|_{adj}^2}{gmax} \right).$$

- As before pixellation provides the relation:

20

$$\sum_{ij} \sin(\phi(i, j)) = 0.$$

- The previous point can now be fulfilled by complex conjugating half the input pixels having the same phase value in the phase histogram.

25

- The phase conjugate phase flipping provides a valuable tool (an extra degree of freedom) for manipulating the spatial frequency content in order to optimize the

separation of low and high frequency terms at the filter plane.

- The scheme is robust to constant phase errors across the input spatial phase modulator, since Eq. (14) is a function of the difference: $\phi_a - \phi(i, j)$, only. Furthermore, small variations in the individual pixel phase values do not introduce any detrimental effects because the average value $\bar{\alpha}$, is a result of a very large phasor sum.
- If the desired intensity distribution is too small to include all energy, that is, the histogram is scaled to maximum and the left hand side of Eq. (16) is still smaller than the right hand side, then the input phase object can be scaled until Eq. (16) is fulfilled. In order to obtain a scale invariant output intensity level a dynamic focusing system is needed. Similarly, intensity invariance can be obtained by controlling the radiated power from the light source. Alternatively, one can ignore the residual background illumination and obtain intensity levels with a gain factor of 9^{-1} (background constant equal to 1^{-1}) for narrow generally shaped line structures (e.g. Eq. (6)).

Example 1:

A very simple example illustrating the individual steps in the above procedure will be given below. To simplify the example it will be considered in one dimension only. The starting point for encoding the spatial phase mask in this example is based on the following parameters:

$$\begin{cases} \bar{\alpha} = 0.5 \\ \theta = \pi \\ \# \text{pix}_{(\Delta x)} = 14 \\ gmax = 4 \end{cases} \quad (20)$$

Consider the pixellated 3-step function shown in Fig. 5 to be synthesized in the image plane as an intensity distribution. From the above choices of parameters one obtains the simple relation between phase values in the spatial phase mask and the image intensity values:

$$|\alpha(i)|^2 = 2[1 - \cos(\phi(i))] \quad (21)$$

10

To proceed from here it necessary to calculate the accumulated intensity $\sum_i |\alpha(i)|^2$ in the image to be synthesized. The accumulated intensity is easily calculated from an image histogram where the x-axis represents greylevel value and the y-axis represents the amount of pixels in the image at a given greylevel value. By use of a histogram $\sum_i |\alpha(i)|^2$ is simply found as the weighted sum of all greylevel values (x-axis) multiplied by their pixel counting (y-axis). This describes, so to speak, the "weight" of the image. In this simple example histogram calculations are not needed since we only have 3 greylevels with well-defined separations.

The value for the accumulated intensity has to obey the equality:

25

$$\sum_i |\alpha(i)|^2 = \frac{gmax}{4} \# \text{pix}_{(\Delta x)} = \# \text{pix}_{(\Delta x)} = 14 \quad (22)$$

From Fig. 5 we obtain:

$$\sum_i |\alpha(i)|^2 = 4\text{pixels} \cdot 0 + 4\text{pixels} \cdot (0.5\text{max}) + 6\text{pixels} \cdot \text{max} = 8\text{max} \quad (23)$$

5 So that the value for max can be estimated to be:

$$\text{max} = \frac{7}{4} \quad (24)$$

The corresponding adjusted intensity levels, $|\alpha(i)|_{\text{adj}}^2$, are
 10 therefore: $7/4$, $7/8$ and 0 . These values can now be
 utilized to calculate the phase values of the spatial
 phase mask from the relation:

$$\phi(i) = \arccos\left(1 - \frac{2|\alpha(i)|_{\text{adj}}^2}{g_{\text{max}}}\right) = \arccos\left(1 - \frac{|\alpha(i)|_{\text{adj}}^2}{2}\right) \quad (25)$$

15

where from we obtain the three phase values: 1.45 rad.
 0.97 rad. and 0 rad.

The last step needed in order to encode the spatial phase
 mask is that the following equality is fulfilled:

20

$$\sum_i \sin(\phi(i)) = 0 \quad (26)$$

Since we have the choice to use complex conjugate phasor
 values (two phasors giving the same intensity level) many
 25 approaches can be taken from here. A simple approach is
 to flip every second phasor with its complex conjugate
 value as shown in Fig. 6. The final phase values used in
 the phase mask are accordingly: ± 1.45 rad. ± 0.97 rad.
 and 0 rad.

30

As the last step we can check whether the criteria:
 $\bar{\alpha} = 1 / 2$, is actually fulfilled with the chosen phasor
encoding:

$$5 \quad \bar{\alpha} = \frac{1}{14} (4 \exp(i0) + 2 \exp(i0.97) + 3 \exp(i1.45) + 2 \exp(-i0.97) + 3 \exp(-i1.45)) = 1 / 2$$

(27)

GENERAL PHASE CORRECTION PROCEDURE INTEGRATED WITH THE PHASE ENCODING

In Eq. (6) we obtained an analytic relation between the
5 phase values in the spatial phase mask and the resulting
intensity distribution, within the region $(x', y') \in \mathfrak{R}'$:

$$|\alpha(x', y')|^2 \cong 1 + 4|\bar{\alpha}| \sin\left(\frac{\theta}{2}\right) \left[|\bar{\alpha}| \sin\left(\frac{\theta}{2}\right) - \sin\left(\phi_a - \phi(x', y') + \frac{\theta}{2}\right) \right] \quad (28)$$

10 The analysis leading to the above relation was based on
the assumption that $|\bar{\alpha}|$ is a constant value within the \mathfrak{R}' -
domain. In other words, the following approximation was
applied:

$$\mathfrak{F}^{-1}\left(\mathfrak{F}(a(x, y))\text{circ}\left(\frac{f_r}{\Delta f_r}\right)\right) \cong \bar{a}\text{rect}\left(\frac{x'}{\Delta x}, \frac{y'}{\Delta y}\right) \quad (29)$$

15

However, for certain spatial filter parameters the
lefthand side of this expression will not be a space
invariant constant value throughout the whole \mathfrak{R}' -domain
but will instead manifest slowly variations/oscillations.
20 This will introduce small errors in the final
superposition between the phase filtered DC-value and the
direct propagated AC-signal. In order to circumvent this
problem a technique is needed that can counteract the
distortions by use of phase-only encoding in the
25 components already present in the system. In what follows
a procedure for integrating predistortion that
counteracts the above mentioned distortions will be
described that is purely based on modifying the phasor
values in the spatial phase mask at the input side of the
30 system. The method can also counteract other types of
distortions inherent in a practical implementation of the
system. Furthermore, the method can be applied in systems
filtering at other spatial frequencies than DC.

Procedure:

When encoding the input phase function it is helpful to have a 'reverse' equation, expressing the input phase
 5 distribution as a function of an adjusted (electronic) image grey-level distribution, I_{slm} , addressing the input spatial light modulator:

$$\frac{4I_{slm}}{gmax} \cong 1 + 4|\bar{\alpha}(x', y')| \sin\left(\frac{\theta}{2}\right) \left[|\bar{\alpha}(x', y')| \sin\left(\frac{\theta}{2}\right) - \sin\left(\phi_{\bar{\alpha}}(x', y') - \phi(x', y') + \frac{\theta}{2}\right) \right] \quad (30)$$

where it has been taken into account that $\bar{\alpha}(x', y')$ is not considered as a constant but manifests a smooth oscillating behaviour within the optical image domain. The maximum value of I_{slm} is denoted $gmax$.

15 Now, one can derive a formula for the 'grey-level correction' $\Delta I_{slm}(x', y')$ that one needs to apply in order to encode a phase function that compensates for the spatial variation of the average phase value $\bar{\alpha}(x', y')$:

$$\begin{cases} \frac{4I_{slm}(x', y')}{gmax} \cong 1 + 4|\bar{\alpha}(x', y')| \sin\left(\frac{\theta}{2}\right) \left[|\bar{\alpha}(x', y')| \sin\left(\frac{\theta}{2}\right) - \sin\left(\phi_{\bar{\alpha}}(x', y') - \phi(x', y') + \frac{\theta}{2}\right) \right] \\ \phi(x', y') = \arccos\left(1 - \frac{2(I_{slm}(x', y') + \Delta I_{slm}(x', y'))}{gmax}\right) \end{cases} \quad (31)$$

where the second relation has been derived from the first by setting $\bar{\alpha} = 1/2$ and $\theta = \pi$.

25 By inserting the second relation in the first expression one gets:

$$\Delta I_{slm}(x', y') = \left(\frac{1}{2|\bar{\alpha}(x', y')|} - 1 \right) I_{slm}(x', y') - \frac{gmax}{2|\bar{\alpha}(x', y')|} \left(|\bar{\alpha}(x', y')| - \frac{1}{2} \right)^2$$

(32)

This formula is however not directly useful because it is related to the histogram adjusted grey-level distribution
5 denoted by I_{slm} .

One needs a formula that relates the above correction term to the 'original' input grey-level distribution $I(x, y)$ that has not been modified by histogram
10 adjustments. This is important since the effect of the grey-level corrections also have to be incorporated in the procedure of histogram adjustments.

The histogram scaling gives:

15

$$I(x, y) = \frac{I_{\max}}{I_{slm, \max}} I_{slm}(x, y) \quad (33)$$

where I_{\max} and $I_{slm, \max}$ are the maximum grey-level values occurring in the original and the adjusted electronic
20 grey-level distributions respectively.

Similarly, one can apply this relation to the intensity correction term ΔI_{slm} and obtain:

$$25 \quad \tilde{I}(x, y) = I(x, y) + \Delta I(x, y) = \frac{I_{\max}}{I_{slm, \max}} (I_{slm}(x, y) + \Delta I_{slm}(x, y)) \quad (34)$$

resulting in:

$$\tilde{I}(x, y) = \frac{1}{2|\bar{\alpha}(x, y)|} \left(I(x, y) - g_{\max} \frac{I_{\max}}{I_{slm, \max}} \left(|\bar{\alpha}(x, y)| - \frac{1}{2} \right)^2 \right) \quad (35)$$

30

In order to have 'enough dynamic range' in grey-levels for the correction term one can derive an inequality from the above relation by using the fact that $\tilde{I}_{\max} \leq g_{\max}$:

$$5 \quad \frac{1}{2|\bar{\alpha}_{\min}|} \left(I_{\max} - g_{\max} \frac{I_{\max}}{I_{slm,\max}} \left(|\bar{\alpha}_{\min}| - \frac{1}{2} \right)^2 \right) \leq g_{\max} \quad (36)$$

or

$$I_{\max} \leq \frac{2|\bar{\alpha}_{\min}| \cdot g_{\max}}{\left(1 - \frac{g_{\max}}{I_{slm,\max}} \left(|\bar{\alpha}_{\min}| - \frac{1}{2} \right)^2 \right)} \quad (37)$$

10 Since the first term is the dominating term in the expression for the intensity correction it will in practice be sufficient just to have the much simpler corrections:

$$\begin{cases} \tilde{I}(x, y) = \frac{I(x, y)}{2|\bar{\alpha}(x, y)|} \\ I_{\max} \leq 2|\bar{\alpha}_{\min}| \cdot g_{\max} \end{cases} \quad (38)$$

PROPOSED APPLICATIONS:

-Laser machining, marking, branding, trimming, hardening, scribing, labeling, welding and cutting on two- and three-dimensional surfaces especially by use of CO₂ and Nd:YAG laser based systems. The main advantage is that energy is not absorbed in the system (thereby preventing damage of the optical hardware) and this nonabsorbed energy is instead utilized to increase the intensity level of the desired light distribution in the image plane. High power can be delivered to selected regions on a work piece simultaneously.

-Efficient and dynamic spot-array generators based on phase contrast imaging. In order to provide bias or holding beams for arrays of optoelectronic elements, such as bistable elements, photonic switches and smart pixels.

-Generation of structured light (lossless) for machine vision applications. E.g. periodic and skew periodic mesh grid illumination that can be updated in parallel.

-Photolithographic applications (laser 3D direct writing in parallel without the need for sequential scanning). E.g. high power laser direct writing of waveguides in Ge-doped silica.

-Spatial light intensity modulation in general by use of pure phase modulation (radiation focusators)

-Laser beam shaping (dynamic).

-Highly efficient parallel image projection without the need for a laser scanning device.

-Dynamic Infrared Scene Projection (DIRSP)

-Exposure device for grating and mask production

-LIDAR applications

-Laserprinting in parallel

-Lasershow applications

-Atmosphere research

CLAIMS

1. A method of decryption of an encrypted image having a non-encrypted image intensity pattern $I(x', y')$ and
 encoded into a mask having a plurality of mask resolution
 5 elements (x_m, y_m) with an encoded phase value $\phi(x_m, y_m)$ and an
 encoded amplitude value $a(x_m, y_m)$, and
 encrypted by addition of an encrypted phase value $\phi_c(x_m, y_m)$
 to the encoded phase values $\phi(x_m, y_m)$ and by multiplication of
 an encrypted amplitude value $a_c(x_m, y_m)$ with the encoded
 10 amplitude value $a(x_m, y_m)$,
 each mask resolution element (x_m, y_m) modulating the phase and
 the amplitude of electromagnetic radiation incident upon it
 with the complex value $a(x_m, y_m) a_c(x_m, y_m) e^{i\phi(x_m, y_m) + i\phi_c(x_m, y_m)}$,
 and
 15 the method comprising the steps of
 radiating electromagnetic radiation towards the mask,
 inserting into the path of the electromagnetic radiation a
 complex spatial electromagnetic radiation modulator
 comprising modulator resolution elements (x_d, y_d) , each
 20 modulator resolution element (x_d, y_d) modulating the phase and
 the amplitude of electromagnetic radiation incident upon it
 with a predetermined complex value $a_d(x_d, y_d) e^{i\phi_d(x_d, y_d)}$, the
 decrypting phase value $\phi_d(x_d, y_d)$ and the decrypting amplitude
 value $a_d(x_d, y_d)$, respectively, of a modulator resolution
 25 element (x_d, y_d) being substantially equal to $-\phi_c(x_m, y_m)$ and
 $a_c^{-1}(x_m, y_m)$, respectively, of a corresponding mask resolution
 element (x_m, y_m) , and
 imaging the mask and the electromagnetic radiation modulator
 onto the image having the image intensity pattern $I(x', y')$.

2. A method according to claim 1, wherein the step of imaging comprises imaging with a common path interferometer.

3. A method according to claim 1 or 2, wherein the step of imaging comprises phase contrast imaging.

5 4. A method according to claim 2 or 3, further comprising the steps of

Fourier or Fresnel transforming electromagnetic radiation modulated by the mask and the complex spatial electromagnetic radiation modulator,

10 filtering the Fourier or Fresnel transformed electromagnetic radiation by

in a region of spatial frequencies comprising DC in the Fourier or Fresnel plane,

15 phase shifting with a predetermined phase shift value θ the modulated electromagnetic radiation in relation to the remaining part of the electromagnetic radiation, and

multiplying the amplitude of the modulated electromagnetic radiation with a constant B, and

20 in a region of remaining spatial frequencies in the Fourier or Fresnel plane, multiplying the amplitude of the modulated electromagnetic radiation with a constant A,

forming the intensity pattern by Fourier or Fresnel
25 transforming, respectively, the phase shifted Fourier or Fresnel transformed modulated electromagnetic radiation, whereby each resolution element (x_m, y_m) of the mask is imaged on a corresponding resolution element (x', y') of the image,

the filtering parameters A, B, θ substantially fulfilling the equation

$$I(x', y') = A^2 |a(x', y') e^{i\phi(x', y')} + BA^{-1} \bar{\alpha} (e^{i\theta} - 1)|^2$$

$\bar{\alpha}$ being the average of the complex phasors $a(x_m, y_m) e^{i\phi(x_m, y_m)}$.

- 5 5. A method according to claim 4, wherein the filtering parameters A and B substantially fulfil that $A=1$ and $B=1$, and for each (x_m, y_m) of the mask: $a(x_m, y_m)=1$.

6. A method according to claim 5, wherein the phase shift value θ substantially fulfils the equation

$$|\bar{\alpha}| = \frac{1}{2|\sin \frac{\theta}{2}|}$$

- 10 7. A method according to claim 6, wherein the phase shift θ is substantially equal to π .

8. A method according to any of claims 3-7, further comprising the steps of

- 15 moving the DC-part of the electromagnetic radiation to a second part of the Fourier or Fresnel plane, and

phase shifting the Fourier or Fresnel transformed modulated electromagnetic radiation at the second part of the Fourier or Fresnel plane by θ in relation to the remaining part of the electromagnetic radiation.

- 20 9. A method according to claim 8, wherein the step of moving the DC-part of the electromagnetic radiation comprises utilization of an optical component, such as a grating, a prism, etc, with an appropriate carrier frequency.

10. A method according to any of claims 3-9, further comprising the step of phase shifting at selected spatial frequencies constituting a region that is shaped to match the spatial frequency content of the phasors $e^{i\phi(x_m, y_m)}$.
- 5 11. A method according to any of claims 3-10, wherein the step of filtering comprises utilization of a spatial light modulator.
12. A method according to any of claims 3-11, further comprising the step of encoding the optical function of an
10 output lens into the filter.
13. A method according to any of claims 3-12, wherein the step of radiating electromagnetic radiation comprises radiation of electromagnetic radiation of different wavelengths corresponding to three different colours, such as
15 red, green and blue, for generation of intensity patterns of arbitrary colours.
14. A method of encryption of an image having an intensity pattern $I(x', y')$ to be decrypted according to any of claims 1-15, comprising the steps of
- 20 pixellating the intensity pattern $I(x', y')$ in accordance with the disposition of resolution elements (x_m, y_m) of a mask,
- encoding the mask with an encoded phase value $\phi(x_m, y_m)$ and an encoded amplitude value $a(x_m, y_m)$, and
- encrypting by addition of an encrypted phase value $\phi_c(x_m, y_m)$
25 to the encoded phase values $\phi(x_m, y_m)$ and by multiplication of an encrypted amplitude value $a_c(x_m, y_m)$ with the encoded amplitude value $a(x_m, y_m)$,
- each mask resolution element (x_m, y_m) modulating the phase and the amplitude of electromagnetic radiation incident upon it
30 with the complex value $a(x_m, y_m)a_c(x_m, y_m)e^{i\phi(x_m, y_m) + i\phi_c(x_m, y_m)}$.

15. A method according to claim 14, further comprising the step of calculating the complex phasor values $a(x_m, y_m)e^{i\phi(x_m, y_m)}$ of the mask in accordance with

$$I(x', y') = A^2 |a(x', y')e^{i\phi(x', y')} + BA^{-1}\bar{\alpha}(e^{i\theta}-1)|^2$$

5 for selected phase shift values θ , $\bar{\alpha}$ being the average of the complex phasors $a(x_m, y_m)e^{i\phi(x_m, y_m)}$,

selecting, for each resolution element, one of two phasor values which represent a particular grey level.

10 16. A method according to claim 15, wherein the filtering parameters A and B substantially fulfil that $A=1$ and $B=1$, and for each (x_m, y_m) of the mask: $a(x_m, y_m)=1$.

17. A method according to claim 16, wherein the step of calculating the phasor values comprises

15 setting the synthesized intensity of at least one resolution element (x_0', y_0') of the intensity pattern to zero, and

calculating the phasor values $e^{i\phi(x, y)}$ of the mask in accordance with

$$|\bar{\alpha}| = \frac{1}{2|\sin \frac{\theta}{2}|}$$

$$I(x', y') = 2[1 + \sin(\phi_{\bar{\alpha}} - \phi(x', y') + \frac{\theta}{2})]$$

for selected phase shift values θ , $\phi_{\bar{\alpha}}$ being the phase of $\bar{\alpha}$.

18. A method according to claim 17, further comprising the
20 step of selecting the phase shift $\theta = \pi$, selecting $|\bar{\alpha}| = \frac{1}{2}$,

and calculating the phasor values $e^{i\phi(x,y)}$ of the phase mask in accordance with

$$I(x',y') = 2[1 - \cos(\phi(x',y'))]$$

$$\int_{\text{mask}} \sin(\phi(x_m, y_m)) dx_m dy_m = 0.$$

19. A method according to any of claims 14-18, further comprising the step of encoding the function of an optical component, such as a grating, a prism, etc, with an appropriate carrier frequency, into the mask.

20. A method according to any of claims 14-19, further comprising the step of adjusting the modulus of the Fourier transform of the complex phasors $a(x_m, y_m)e^{i\phi(x_m, y_m)}$ at specific spatial frequencies in order to control the range of intensity levels of the synthesized intensity pattern.

21. A method according to claim 20, wherein the step of adjusting the modulus of the Fourier transform of the complex phasors $a(x_m, y_m)e^{i\phi(x_m, y_m)}$ at specific spatial frequencies comprises at least one of the following measures:

- a) adjusting the individual complex phasors $a(x_m, y_m)e^{i\phi(x_m, y_m)}$ of the resolution elements of the mask maintaining prescribed relative intensity levels between intensities of resolution elements of the intensity pattern,
- b) adjusting the individual complex phasors $a(x_m, y_m)e^{i\phi(x_m, y_m)}$ of the resolution elements of the mask by histogram techniques,
- c) spatially scaling the complex phasor $a(x_m, y_m)e^{i\phi(x_m, y_m)}$ pattern of the mask, and

d) utilizing half tone coding techniques.

22. A method according to any of claims 14-21, wherein each complex phasor $a(x_m, y_m)e^{i\phi(x_m, y_m)}$ of the mask is selected from a set of two determined phasors with complementary complex
 5 phasor values $a(x_m, y_m)e^{i\phi_1(x_m, y_m)}$ and $a(x_m, y_m)e^{i\phi_2(x_m, y_m)}$ in such a way that a specific spatial frequency distribution of the intensity of the electromagnetic radiation in the Fourier or Fresnel plane is attained.

23. A method according to claim 22, wherein the phase $\phi(x, y)$
 10 of complex phasors $a(x_m, y_m)e^{i\phi(x_m, y_m)}$ of adjacent resolution elements alternates between the two possible complementary complex phasor values $a(x_m, y_m)e^{i\phi_1(x_m, y_m)}$ and $a(x_m, y_m)e^{i\phi_2(x_m, y_m)}$.

24. A method according to claim 22 or 23, wherein the complex
 15 phasors $a(x_m, y_m)e^{i\phi_1(x_m, y_m)}$ and $a(x_m, y_m)e^{i\phi_2(x_m, y_m)}$ are complex conjugated.

25. A method according to any of claims 14-24, further comprising the step of encoding the optical function of a Fourier-transforming lens into the complex phasors
 20 $a(x_m, y_m)e^{i\phi(x_m, y_m)}$ of the mask.

26. A decryption system for decrypting an encrypted image having a non-encrypted image intensity pattern $I(x', y')$ that has been

encoded into a mask having a plurality of mask resolution
 25 elements (x_m, y_m) with an encoded phase value $\phi(x_m, y_m)$ and an encoded amplitude value $a(x_m, y_m)$, and

encrypted by addition of an encrypted phase value $\phi_c(x_m, y_m)$ to the encoded phase values $\phi(x_m, y_m)$ and by multiplication of an encrypted amplitude value $a_c(x_m, y_m)$ with the encoded
 30 amplitude value $a(x_m, y_m)$,

each mask resolution element (x_m, y_m) modulating the phase and the amplitude of electromagnetic radiation incident upon it with the complex value $a(x_m, y_m) a_c(x_m, y_m) e^{i\phi(x_m, y_m) + i\phi_c(x_m, y_m)}$,

the system comprising

- 5 a source of electromagnetic radiation for emission of electromagnetic radiation,

positioned in the path of the electromagnetic radiation a complex spatial electromagnetic radiation modulator comprising modulator resolution elements (x_d, y_d) , each

- 10 modulator resolution element (x_d, y_d) modulating the phase and the amplitude of electromagnetic radiation incident upon it with a predetermined complex value $a_d(x_d, y_d) e^{i\phi_d(x_d, y_d)}$, the decrypting phase value $\phi_d(x_d, y_d)$ and the decrypting amplitude value $a_d(x_d, y_d)$, respectively, of a modulator resolution
- 15 element (x_d, y_d) being substantially equal to $-\phi_c(x_m, y_m)$ and $a_c^{-1}(x_m, y_m)$, respectively, of a corresponding mask resolution element (x_m, y_m) , and

an imaging system for imaging the mask and the electromagnetic radiation modulator onto the image having the

- 20 image intensity pattern $I(x', y')$.

27. A system according to claim 26, wherein the imaging system comprises a common path interferometer.

28. A system according to claim 26 or 27, wherein the imaging system comprises a phase contrast imaging system.

- 25 29. A system according to claim 27 or 28, further comprising

means for Fourier or Fresnel transforming the electromagnetic radiation modulated by the mask and the complex spatial electromagnetic radiation modulator and being positioned on a propagation axis of the modulated radiation,

a spatial filter for filtering the Fourier or Fresnel transformed electromagnetic radiation by

in a region of spatial frequencies comprising DC in the Fourier or Fresnel plane,

5 phase shifting with a predetermined phase shift value θ the modulated electromagnetic radiation in relation to the remaining part of the electromagnetic radiation, and

10 multiplying the amplitude of the modulated electromagnetic radiation with a constant B, and

in a region of remaining spatial frequencies in the Fourier or Fresnel plane, multiplying the amplitude of the modulated electromagnetic radiation with a constant A,

15 means for forming the intensity pattern by Fourier or Fresnel transforming, respectively, the phase shifted Fourier or Fresnel transformed modulated electromagnetic radiation, whereby each resolution element (x_m, y_m) of the mask is imaged on a corresponding resolution element (x', y') of the image,

20 the filtering parameters A, B, θ substantially fulfilling the equation

$$I(x', y') = A^2 |a(x', y') e^{i\phi(x', y')} + BA^{-1} \bar{\alpha} (e^{i\theta} - 1)|^2$$

for selected phase shift values θ , $\bar{\alpha}$ being the average of the complex phasors $a(x_m, y_m) e^{i\phi(x_m, y_m)}$.

25 30. A system according to claim 29, wherein the filtering parameters A and B substantially fulfil that $A=1$ and $B=1$, and for each (x_m, y_m) of the mask: $a(x_m, y_m)=1$.

31. A system according to claim 30, wherein the phase shift value θ substantially fulfils the equation

$$|\bar{\alpha}| = \frac{1}{2|\sin\frac{\theta}{2}|}$$

32. A system according to claim 31, wherein the phase shift θ is substantially equal to π .

5 33. A system according to any of claims 28-31, further comprising

means for moving the region of spatial frequencies comprising DC to a second part of the Fourier or Fresnel plane, and wherein

10 the spatial filter is adapted to phase shift the transformed modulated electromagnetic radiation at the second part of the Fourier or Fresnel plane by θ in relation to the remaining part of the electromagnetic radiation.

15 34. A system according to claim 33, wherein the means for moving the region of spatial frequencies comprising DC to a second part of the Fourier or Fresnel plane comprises an optical component, such as a grating, a prism, etc, with an appropriate carrier frequency.

20 35. A system according to any of claims 29-34, wherein the spatial filter comprises a spatial light modulator.

36. A system according to any of claims 29-35, wherein the spatial filter is adapted to perform the optical function of an output lens by appropriate encoding of the spatial filter.

25 37. A system according to any of claims 26-36, wherein the source of electromagnetic radiation is adapted to radiate electromagnetic radiation of different wavelengths

corresponding to three different colours, such as red, green and blue, for generation of intensity patterns of arbitrary colours.

38. A system according to any of claims 29-37, further
5 comprising a first and a second Fourier transforming lens,
the mask being positioned in the front focal plane of the
first lens, the spatial filter being positioned at the back
focal plane of the first lens, and the second lens being
positioned so that its front focal plane is positioned at the
10 position of the back focal plane of the first lens.

39. A system according to any of claims 29-38, further
comprising one Fourier transforming lens, the spatial filter
being positioned at the back focal plane of the lens.

40. A system according to any of claims 29-39, further
15 comprising one imaging lens, the spatial filter being
positioned in the back focal plane of the lens.

41. A system according to any of claims 29-40, further
comprising a polarizing beam splitter and a quarter wave
plate and/or a phase filter reflecting electromagnetic
20 radiation incident upon it.

42. A system according to any of claims 29-41, wherein the
spatial filter changes the phase of the radiation in the
region of spatial frequencies comprising DC and leaves the
phase of the remaining part of the radiation unchanged.

25 43. A system according to any of claims 29-41, wherein the
spatial filter do not change the phase of the radiation in
the region of spatial frequencies comprising DC and changes
the phase of the remaining part of the radiation.

44. A system according to any of claims 29-41, wherein the spatial filter blocks the radiation at the region of spatial frequencies comprising DC and leaves the remaining part of the radiation unchanged.

- 5 45. A system according to any of claims 29-44, wherein the source of electromagnetic radiation is a Laser.

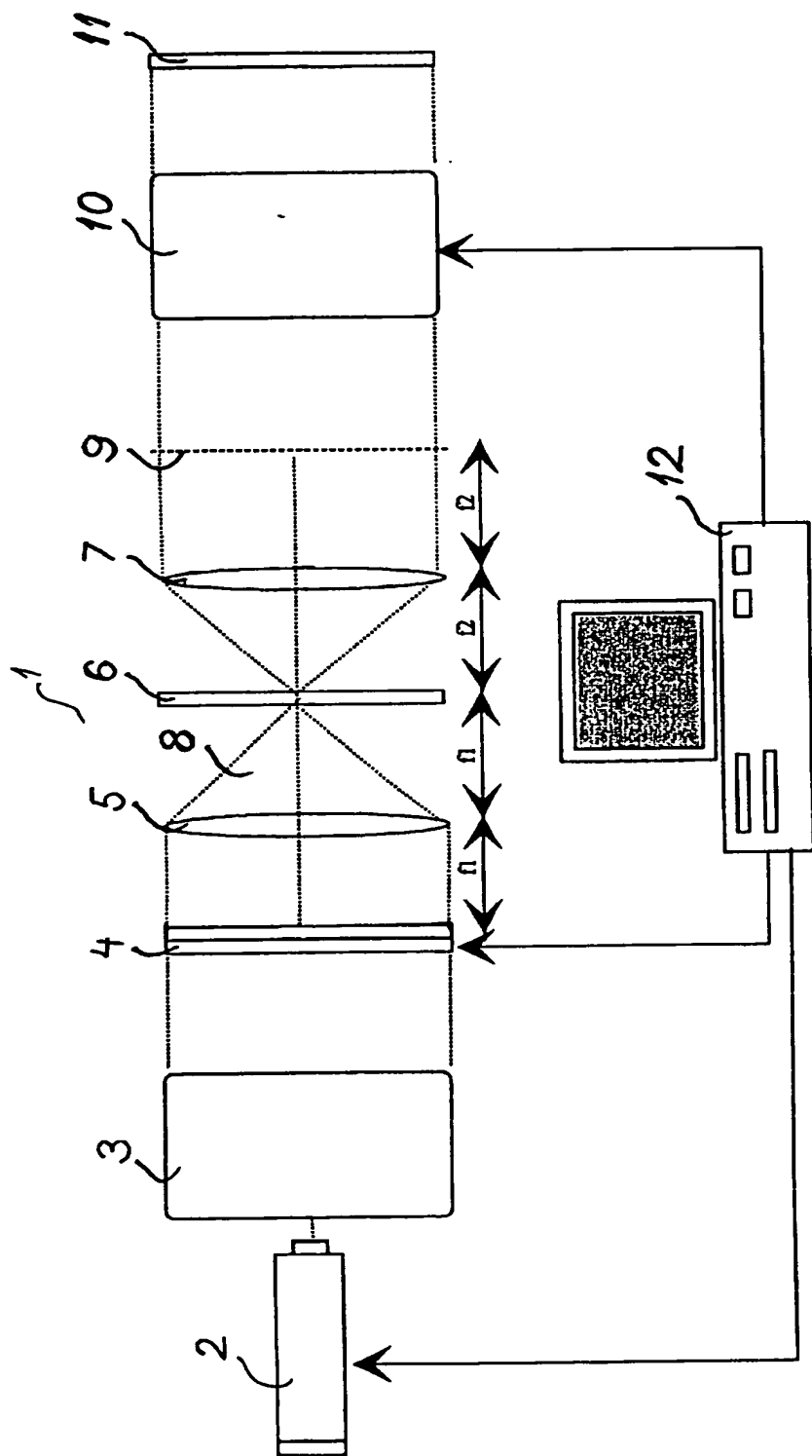


Fig. 1

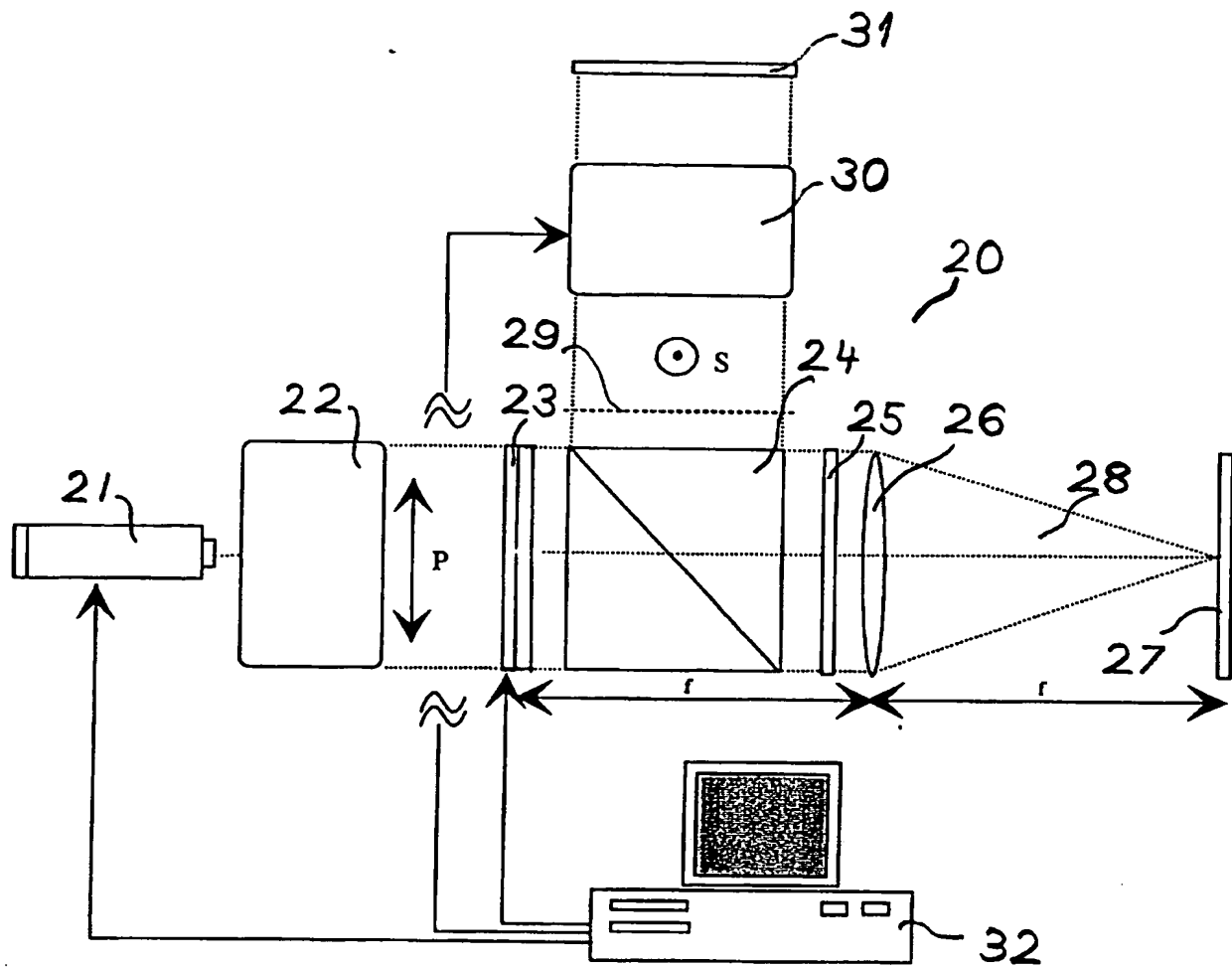


Fig. 2

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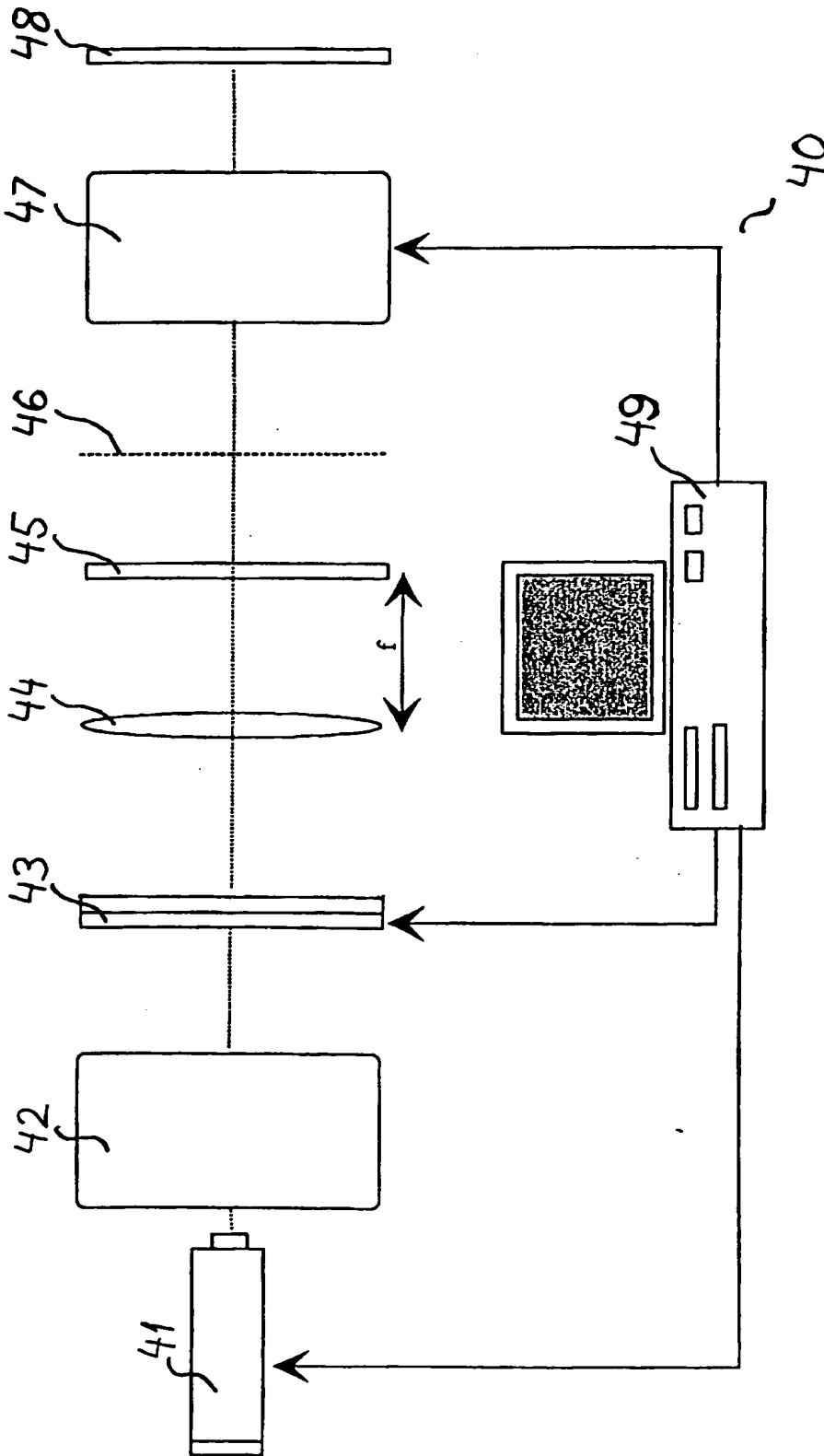
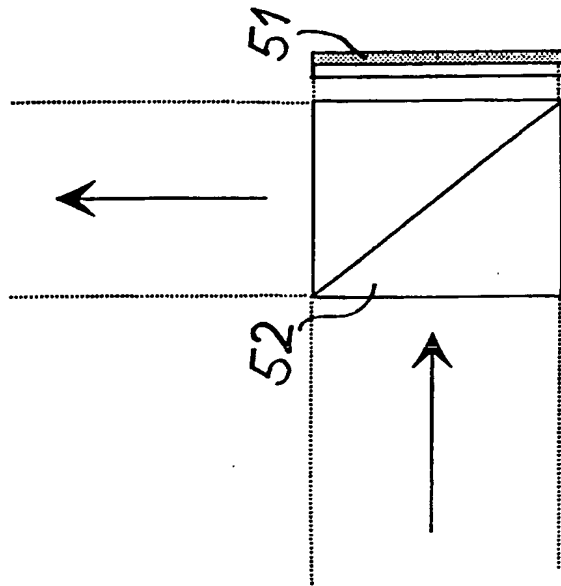
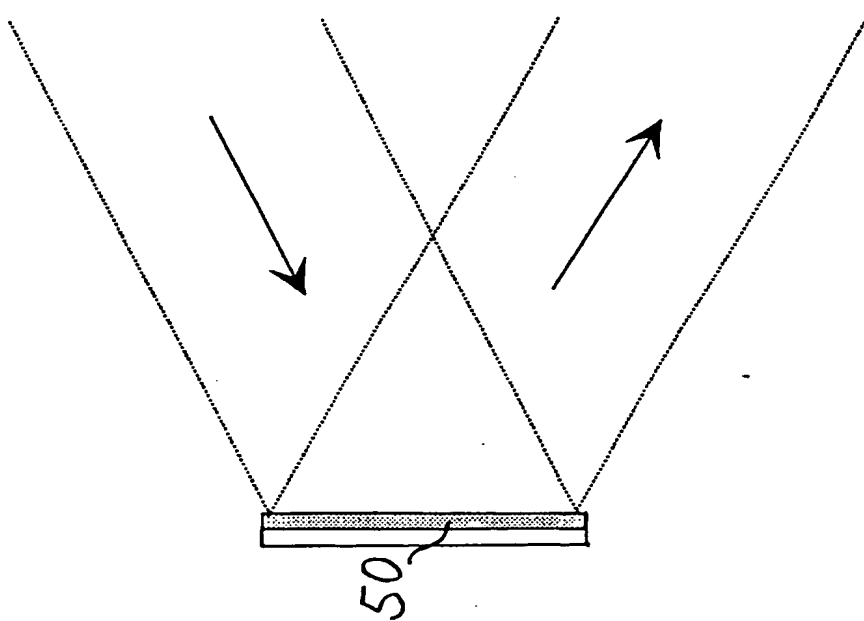


Fig. 3

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(B)



(A)

Fig. 4

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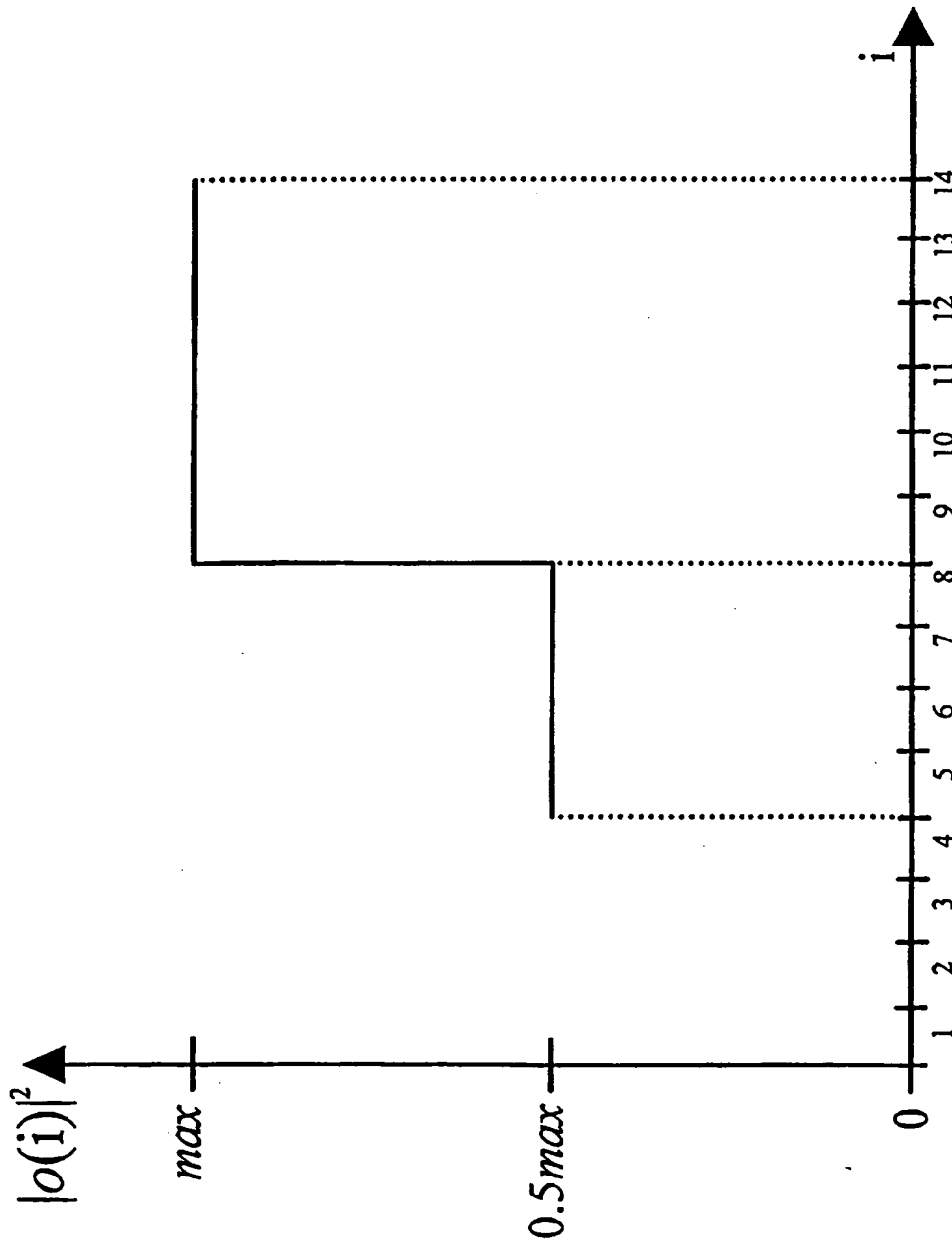


Fig. 5

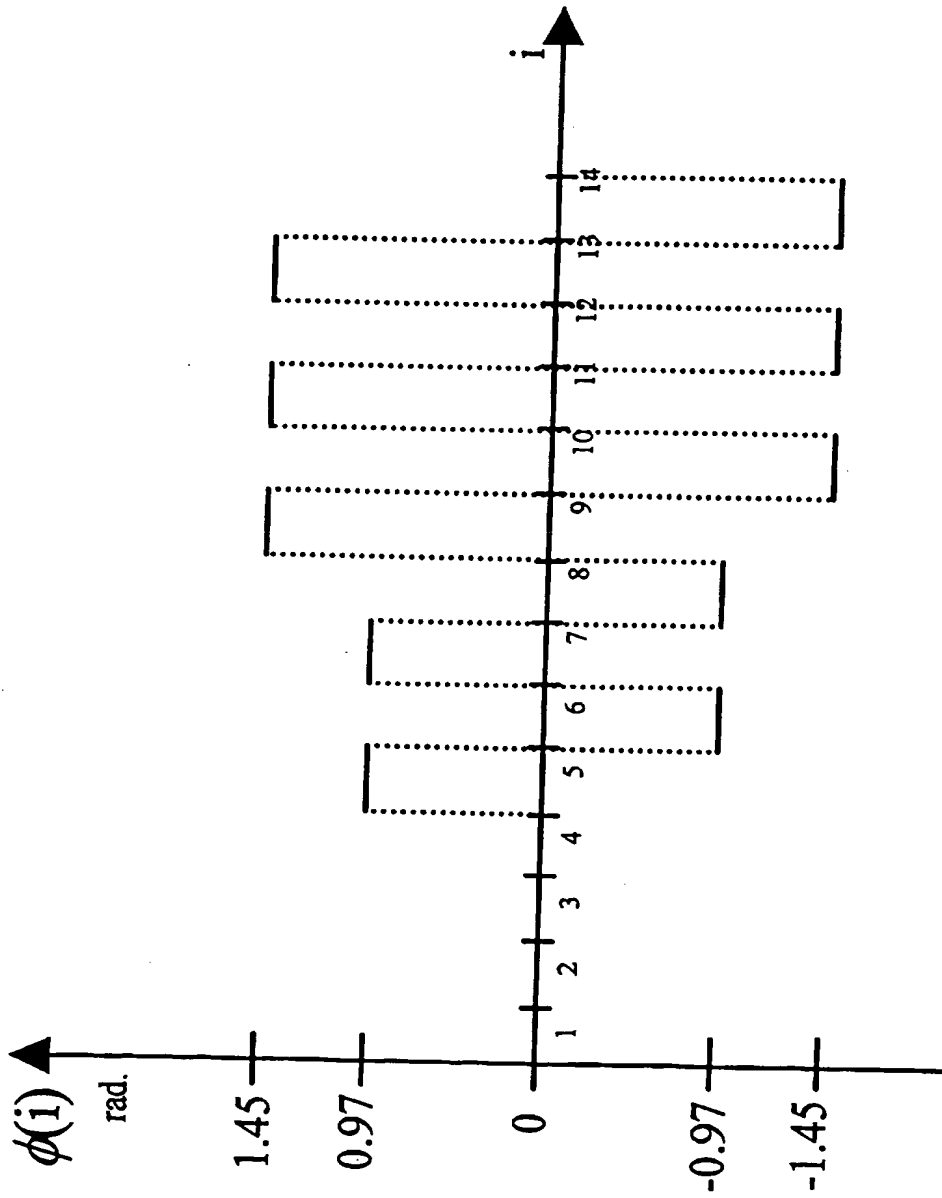


Fig. 6

